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APPLICATION NUMBER	FILING or 371(c) DATE	GRP ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	TOT CLAIMS	IND CLAIMS
10/564,317	01/12/2006	2617	2050	277147US6PCT	13	6

CONFIRMATION NO. 7397

CORRECTED FILING RECEIPT

22850
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ALEXANDRIA, VA 22314



Date Mailed: 11/08/2011

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Assignment For Published Patent Application

Sony Corporation, Tokyo, JAPAN

Power of Attorney: The patent practitioners associated with Customer Number 22850

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP04/07016 05/18/2004

Foreign Applications (You may be eligible to benefit from the **Patent Prosecution Highway** program at the USPTO. Please see <http://www.uspto.gov> for more information.)

JAPAN 2003-274302 07/14/2003

JAPAN 2003-291741 08/11/2003

JAPAN 2003-313167 09/04/2003

JAPAN 2003-341331 09/30/2003

If Required, Foreign Filing License Granted: 05/03/2006

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US 10/564,317**

Projected Publication Date: Not Applicable

Non-Publication Request: No

Early Publication Request: No
Title

COMMUNICATION DEVICE, COMMUNICATION METHOD FOR COMMUNICATION DEVICE, AND
COMMUNICATION PROGRAM FOR COMMUNICATION DEVICE

Preliminary Class

455

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